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CHARGED PARTICLE RADIATION DAMAGE IN SEMICONDUCTORS, III:

THE ENERGY DEPENDENCE  
OF PROTON DAMAGE IN SILICON

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SPACE TECHNOLOGY LABORATORIES, INC.  
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TORRANCE BEACH, CALIFORNIA



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THE ENERGY DEPENDENCE OF PROTON DAMAGE IN SILICON

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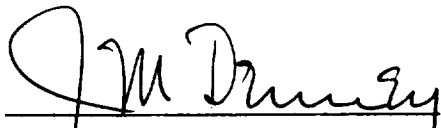
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Material Sciences Department

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## I. INTRODUCTION

In a previous report<sup>1</sup>, henceforth designated as A, theoretical calculations were made to determine the radiation damage in silicon due to high energy protons ( $10 \text{ Mev} \leq E_p \leq 2000 \text{ Mev}$ ). Since that time, more detailed calculations, involving refinements in some of the theoretical expressions and the inclusion of some additional "second-order" effects, have modified slightly the results quoted in A. These changes will not be described in detail.

As described in A, the spallation mechanism between an incident proton and a silicon target nucleus is a two-stage phenomenon, first involving a cascade interaction, followed by an evaporation stage. In A, it was assumed that the target nucleus, after recoiling from the cascade interaction with an energy  $E_{RN}$ , emitted isotropically a number of nucleons in the evaporation stage, before slowing to rest by collisions with atoms in the silicon lattice. In calculating the defect density due to this recoiling nucleus by Equation (8) of A, account was taken of both the fast nucleons  $M_{FP}$  and  $M_{FN}$  lost in the cascade, and the slow nucleons  $M_{SP}$  and  $M_{SN}$  emitted in the evaporation. However, it was assumed that the energy of the recoil nucleus,  $E_{RN}$ , was not changed during the evaporation process.

In the present paper, we shall describe the changes in the defect density due to the following two modifications: (1) a more detailed and accurate calculation, using the theory of LeCouteur<sup>2</sup>, of the number of slow nucleons emitted; and (2) a calculation of the change in  $E_{RN}$  during the evaporation, a phenomenon previously neglected.

## II. NUMBER OF SLOW NUCLEONS EMITTED

During the evaporation stage, the recoil nucleus, with excitation  $E^*$ , de-excites by the isotropic emission of nucleons and other lightweight particles ( $A \leq 4$ ). We neglect all these particles except the nucleons ( $A = 1$ ). In A, average values were assumed for the energies  $e_p$  and  $e_n$  carried off in the emissions of protons and neutrons, respectively. Thus, for a given initial  $E^*$ , it was possible to calculate  $M_{SP}$  and  $M_{SN}$ . A more detailed analysis, however, shows that  $e_p$  and  $e_n$  increase with increasing



$E^*$ , so that the use of average values may lead to erroneous results. In the new calculation, a step-by-step analysis of the evaporation was made, beginning with an initial excitation energy  $E^*$ , and continuing until enough nucleons had been emitted to reduce  $E^*$  to about 7 Mev, below which no further nucleon emission is possible. For each step in the emission process, the actual  $e_p$  or  $e_n$  for that  $E^*$  was calculated, rather than using an average value as in paper A. Figure 1 shows the difference produced by the two methods. The graph shows the total number of slow nucleons,  $M_S = M_{SP} + M_{SN}$ , as a function of the incident proton energy  $E_p$ . It is seen that the more accurate analysis leads to smaller values of  $M_S$  than the earlier calculations. This in turn increases the defect density  $\rho_i$  due to the recoiling nucleus, as is obvious from Figure 1 of A. If  $M_S$  is smaller, then  $(Z_1, A_1)$  are larger, and for a given  $E$ , the value of  $\mathcal{V}(E)$  increases. Since  $\rho_i$  is directly proportional to  $\mathcal{V}(E)$  by Equations (7) and (8) of A, then  $\rho_i$  also increases if  $M_S$  decreases.

### III. CHANGE OF RECOIL ENERGY $E_{RN}$ IN EVAPORATION

In the previous paper, the increase in the recoil energy of the target nucleus, due to the emission of evaporated nucleons, was neglected for the following reason. From Figure 1 of A, it will be noted that in the energy range of interest ( $0.5 \text{ Mev} \leq E \leq 20 \text{ Mev}$ ), a 100 per cent change in  $E$  makes no more than about a 20 per cent change in  $\mathcal{V}(E)$ , which is smaller than some of the other errors in  $\mathcal{V}(E)$ , such as that discussed in Section II above. However, now that the larger error (in  $M_S$ ) has been corrected, the error in  $E_{RN}$  was also removed.

Let us consider the momentum balance in the emission of a nucleon. Letting  $P_i$  and  $P_f$  be the initial and final momenta of the nucleus, which initially has mass number  $A$ , and  $P_o$  be the momentum of the emitted nucleon, then:

$$\underline{P}_f = \underline{P}_i - \underline{P}_o \quad (1)$$



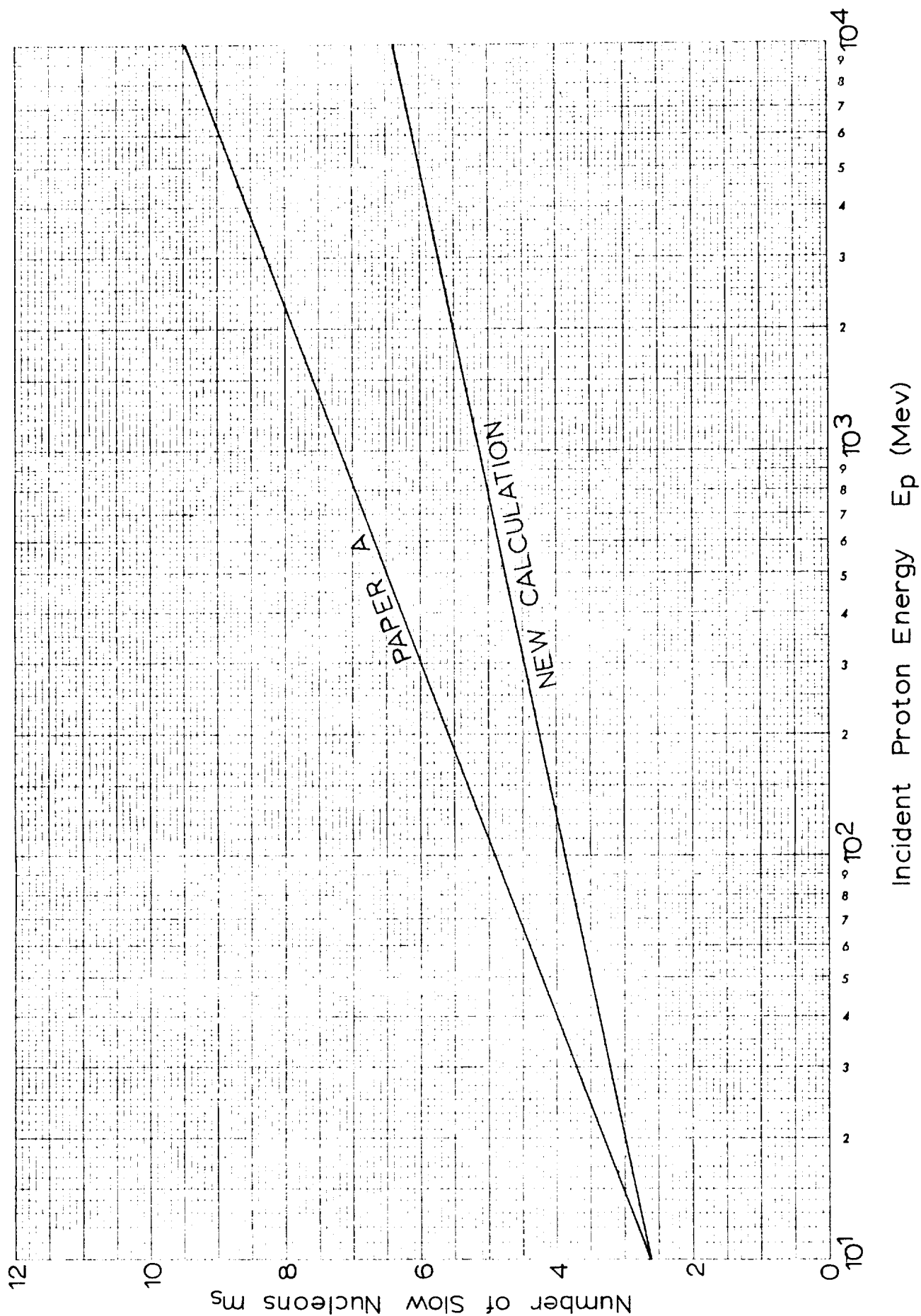


Figure 1. Number of Slow Nucleons Emitted by Excited Nucelus During Evaporation Stage



Taking the scalar product  $\underline{P}_f \cdot \underline{P}_f$  we obtain:

$$P_f^2 = P_i^2 + P_o^2 - 2 (\underline{P}_i \cdot \underline{P}_o) \quad (2)$$

Under the assumption that the nucleons are evaporated isotropically, it follows that on the average we can write:

$$(\underline{P}_i \cdot \underline{P}_o)_{Ave} = 0 \quad (3)$$

For nonrelativistic energies,  $E = P^2/2m$ , so that (2) becomes:

$$2 (A-1) E_f^{RN} = 2AE_i^{RN} + 2E_o \quad (4)$$

where  $E_o$  is either the calculated value  $e_p$  or  $e_n$ , depending on whether a proton or a neutron was emitted in this step. Thus, we obtain finally:

$$E_{i+1}^{RN} = \frac{A_i E_i + E_o}{A_i - 1} \quad (5)$$

for the energy of the recoil nucleus after emission of the  $i$ th nucleon. Figure 2 shows the increase in  $E_{RN}$  over the previous value. The average increase is approximately 60 to 70 per cent, and this produces roughly a 10 per cent increase in  $\mathcal{V}(E)$ .

#### IV. EFFECT OF CHANGES ON DEFECT DENSITY

The combined effect of changes in  $M_S$  and  $E_{RN}$  was calculated from Figure 1 of A, and the corresponding change in Figure 2 of A was obtained. Figure 3 contains both the old values of the defect density ( $\rho_t, \rho_e, \rho_i$ ) versus proton energy  $E_p$  as shown in Figure 2 of A, and also the new values of  $\rho_t$  and  $\rho_i$  from the present calculations.

It can be seen that the increase in  $\rho_i$  is 15 to 50 per cent while the corresponding change in  $\rho_t$  is 10 to 25 per cent. The resulting change in





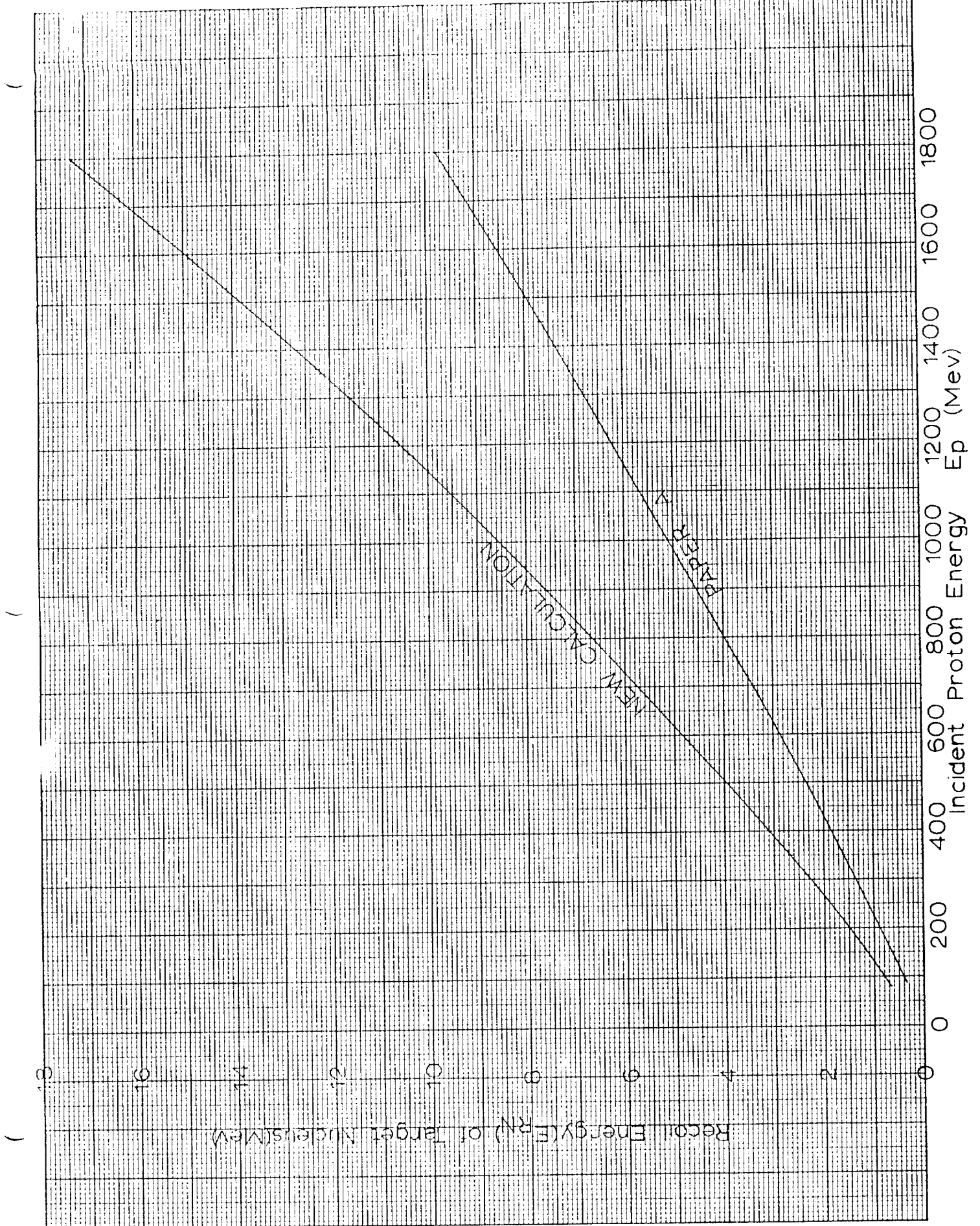


Figure 2. Recoil Energy of Target Nucleus Due to a High Energy Proton Bombardment



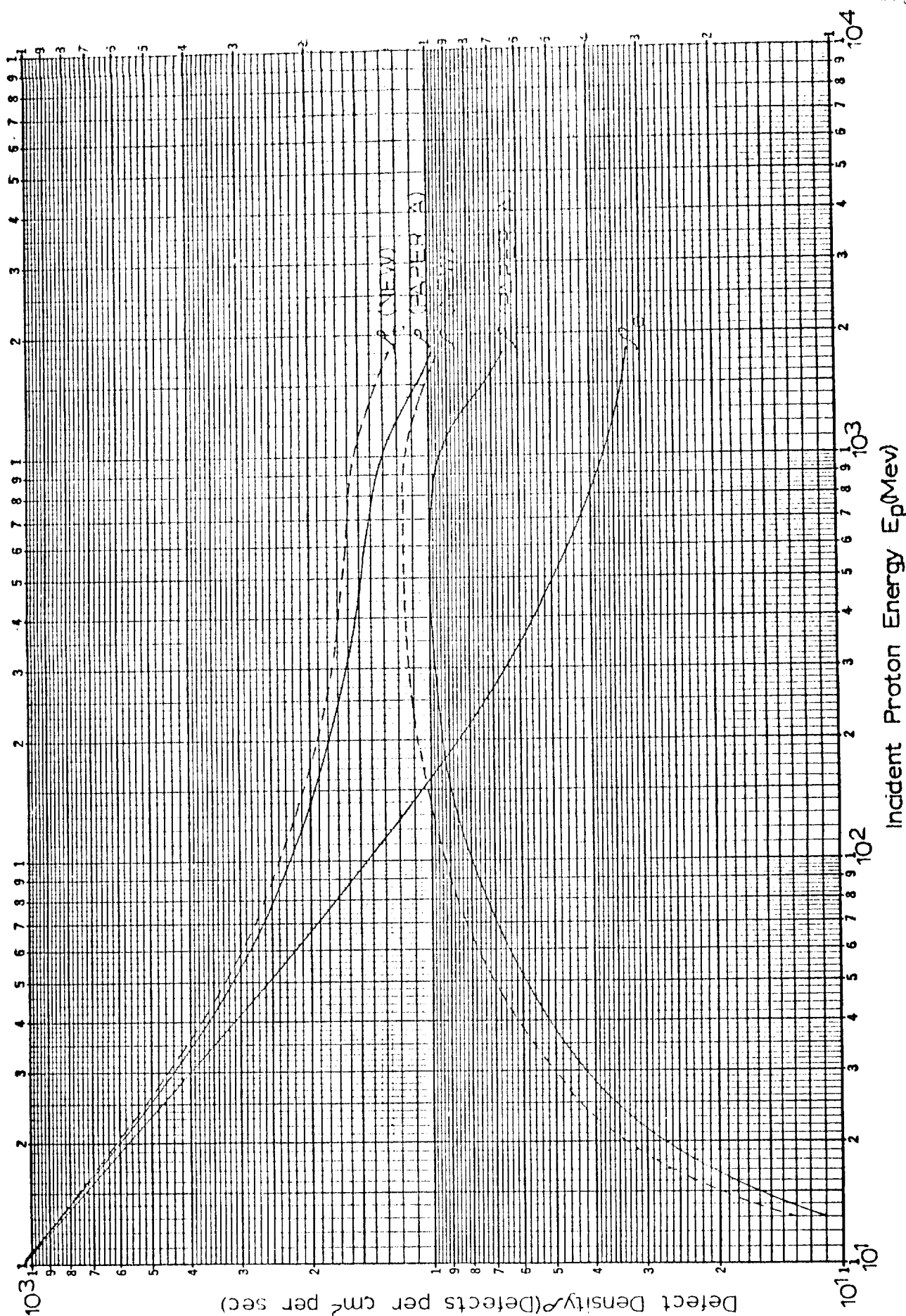


Figure 3. Calculated Defect Density in Silicon Due to High Energy Protons



the ratio  $\rho_t(95.5 \text{ Mev})/\rho_t(450 \text{ Mev})$  of Table I, Paper A, is from 1.53 to 1.48.

These results have been incorporated in the article submitted by the authors for publication in the Physical Review, to be published in March, 1963.

#### V. DISCUSSION

Although the absolute value of the defect density has been changed somewhat by the present calculations, the general shape of the defect density versus energy curves has not been altered.

In addition, the greatest uncertainty in the computation of the defect density has unfortunately not been resolved by these revised calculations; that is, the relative importance and different consequences of isolated point defects versus defect "clumps" or "spikes". Further theoretical calculations will be directed toward the solution of this difficult problem.



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